

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of) Attorney Docket No.: **SOEI0021**
Ken SAWABE et al.) Confirmation No. 9014
Serial No.: 10/595,920) Group Art Unit: 1795
Filed: May 19, 2006) Examiner: Amanda C. WALKE
For: PHOTOSENSITIVE RESIN) Date: July 13, 2009
COMPOSITION, PHOTOSENSITIVE)
ELEMENT, RESIST PATTERN)
FORMING METHOD AND PROCESS)
FOR MANUFACTURING PRINTED)
CIRCUIT BOARD)

TELEPHONE INTERVIEW SUMMARY (F)

MAIL STOP: ISSUE FEE

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Sir:

In view of the telephone interview conducted on July 13, 2009 between Applicants' attorney, Wesley Ashton, and Examiner Amanda Walke (571-272-1337), please enter the following remarks in the application identified above in accordance with MPEP § 713.04:

Remarks/Arguments begin on page 2 of this paper.